L Number	Hits	Search Text	DB	Time stamp
1	536104	resist or photoresist or pr	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 17:15
2	13167	silylat$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 17:15
3	176	((((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain) same mask$4) and (@ad < "20030826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 17:15
4	0	silylat$4 and (((((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain) same mask$4) and (@ad < "20030826"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 17:15

L Number	Hits	Search Text	DB	Time stamp
-	63	(resist or photoresist or pr) same silylat$4 same (oxidat$4 or oxidiz$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 14:24
-	43	((taper$4 or round$4 or facet$4) same (((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting)))) and (semiconductor or silicon or si!)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:31
-	3891	((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:32
-	2811039	ldd or light$4 near2 dop$4 or source or drain	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:33
-	598	(((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:33
-	76	(((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain) near8 mask$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:34
-	177	(((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain) same mask$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:37
-	176	((((angl$4 or inclin$4 or theta or phi or slant$4 or tilt$4) near4 (inplant or implant or inplanting or implanting))) near8 (ldd or light$4 near2 dop$4 or source or drain) same mask$4) and (@ad < "20030826")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 15:38
1	869	((438/302) or (438/184) or (438/185) or (438/525)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/25 16:41